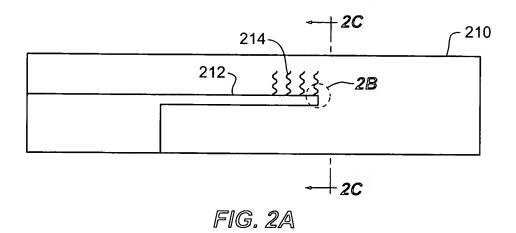


FIG. 1



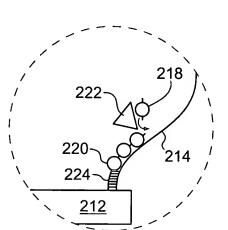


FIG. 2B

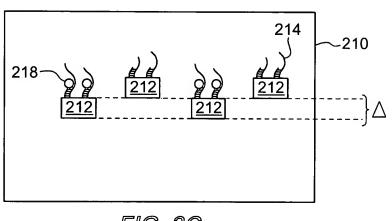
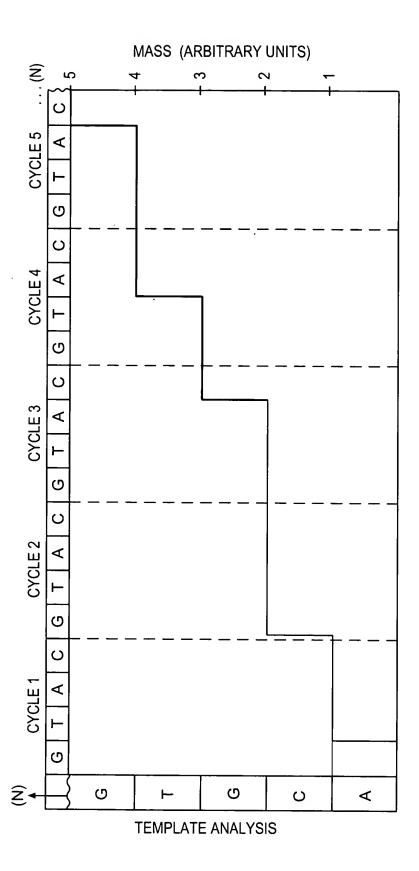
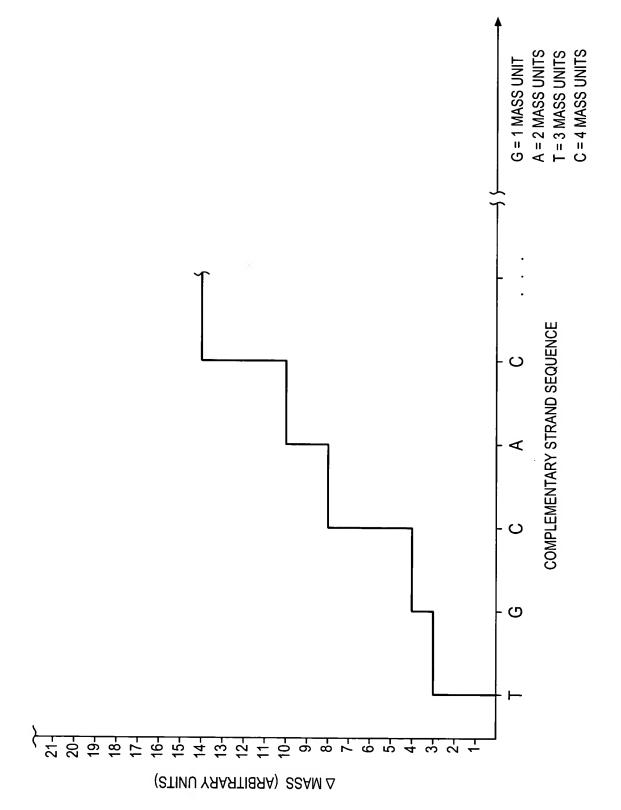


FIG. 2C



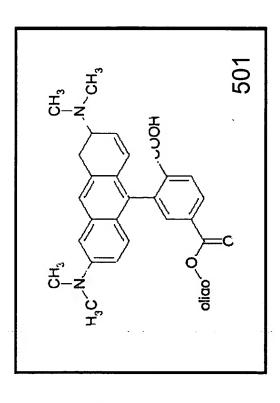
F/G. 3



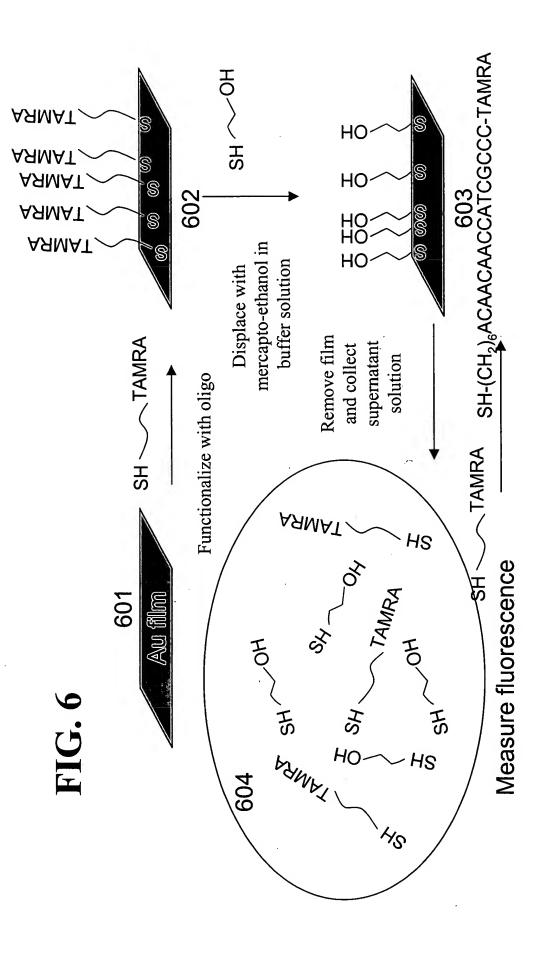
F/G. 4

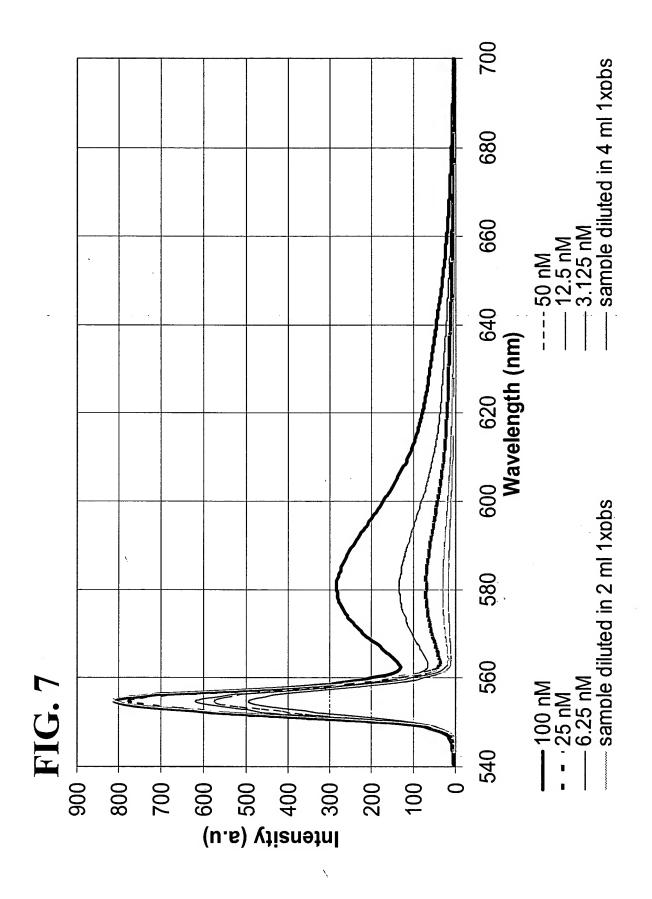
## FIG.5

- To confirm attachment of thiol-modified oligo (SH-1-f)
  [ThiSS]ACAACAACCATCGC CC-TAMRA) to a gold thin film and to determine the surface coverage
- Gold substrates prepared by sputtering using Metallica sputterer at SNF
- Ti 50 A, Au 1000 A on Silicon



**TAMRA** λ<sub>max,A</sub>: 555 nm λ<sub>max,E</sub>: 580 nm





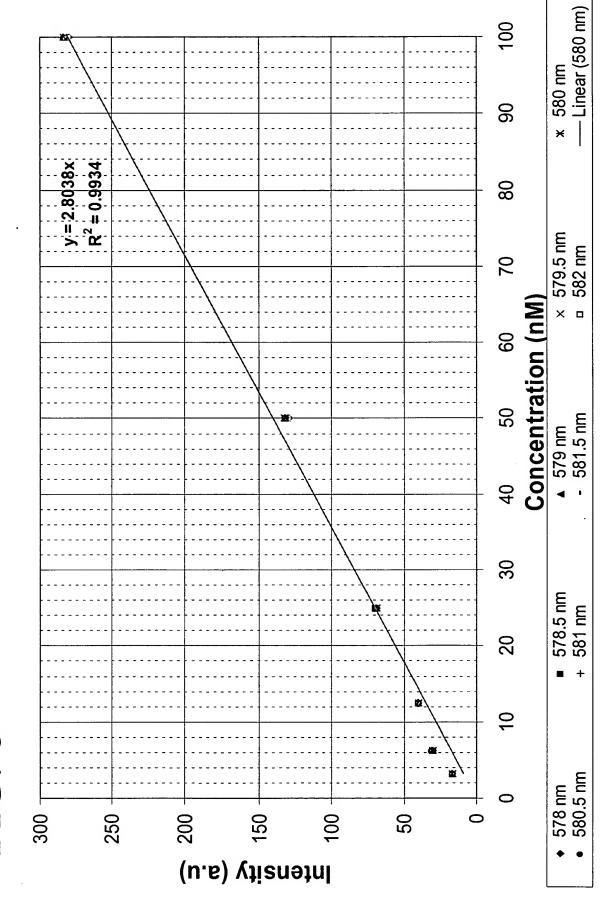


FIG. 8

FIG. 9

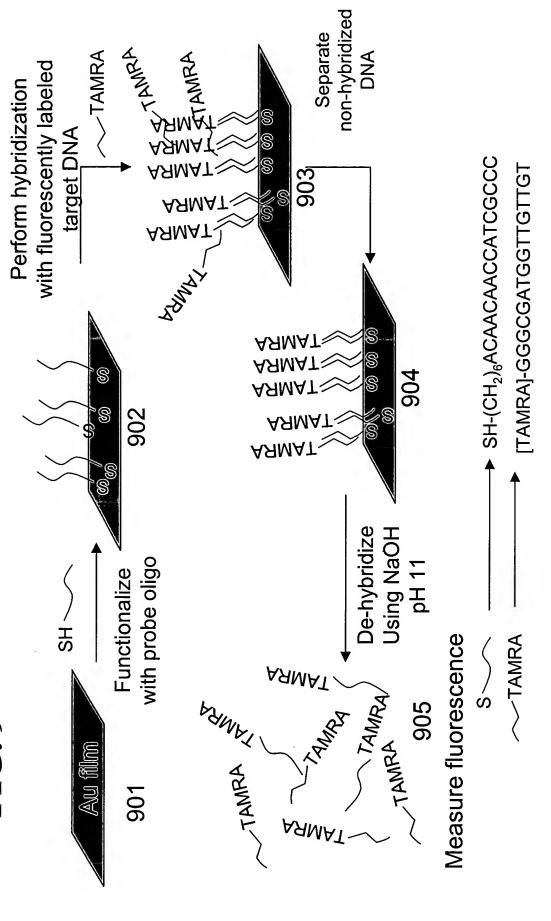


FIG.10

